# Sigma-Aldrich<sub>®</sub>

**Product Information** 

# Adenosine 5'-monophosphate Agarose

Lyophilized powder

#### A1271

# **Product Description**

Adenosine 5'-monophosphate-Agarose (5'-AMP-agarose) is a conjugate of 5'-AMP to cross-linked 4% beaded agarose (activated by cyanogen bromide), via the C-8 atom of 5'-AMP. 5'-AMP-agarose is used in studies of NAD+-dependent dehydrogenases and ATP-dependent enzymes.

5'-AMP-agarose is useful in affinity chromatography for purifying various enzymes, such as:

- Aldehyde dehydrogenase<sup>1</sup>
- DNA polymerase δ<sup>2</sup>
- DNA polymerase ε<sup>3</sup>
- Lactate Dehydrogenase Isoenzyme-5<sup>4</sup>
- NADH oxidase<sup>5</sup>

### Storage/Stability

- The lyophilized 5'-AMP-agarose resin should be stored at -20 °C.
- Hydrated 5'-AMP-agarose resin can be stored refrigerated in neutral pH buffer that contains a bacteriostat, such as 0.02% sodium azide or thimerosal, or 20% ethanol.
- Do not autoclave or freeze the hydrated resin.
- The resin can be used several times without loss of effectiveness.

# **Preparation Instructions**

- The 5'-AMP-agarose resin may be hydrated by the addition of excess water, e.g. 100-150 mL per gram of resin, depending on the observed degree of swelling, for at least 30 minutes.
- The lactose stabilizer may be removed by washing the resin on a Buchner funnel with gentle vacuum, using 100-200 mL of water per gram of resin.
- Do not allow the resin to dry.
- The washed resin may then be resuspended in excess water or starting buffer, to pack the column bed.

#### Procedure

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Used 5'-AMP-agarose resin may be regenerated by washing the resin with 2-3 bed volumes of buffers in a cycle with alternating mildly basic and mildly acidic buffers, such as the following buffers:

- 0.1 M Trizma®-HCl plus 0.5 M NaCl, pH 8.5
- 0.1 M sodium acetate plus 0.5 M NaCl, pH 4.5

Three buffer wash cycles are suggested. The washed resin should then be re-equilibrated in 3-5 bed volumes of the desired binding buffer.

In situations where difficult-to-elute materials, such as lipids or denatured proteins, have become entrapped on the resin, a dilute detergent solution, such as 0.1% Triton<sup>TM</sup> X-100, may be used to wash the resin at 37 °C. The resin should then be immediately re-equilibrated with a minimum of 5 bed volumes of the desired binding buffer.



#### References

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- 4. Pettit, S.M. *et al.*, *Clin. Chem.*, **27(1)**, 88-93 (1981).
- 5. Brown, D.M. et al., Eur. J. Biochem., **241(1)**, 155-161 (1996).

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